

AMENDMENTS TO THE SPECIFICATION

Pursuant to 37 C.F.R. § 1.121, please amend the Specification as follows:

On page 1, line 24, please amend the text as follows:

-- U.S. Ser. No. 10/734,623 filed 15 Dec. 2003, now U.S. Patent No. 6,995,930, issued February 7, 2006, --

On page 2, lines 3-6, please amend the text as follows:

-- Of these, e.g. WO 2004/019 128 A2, U.S. Ser. No. 10/734,623, now U.S. Patent No. 6,995,930, issued February 7, 2006, U.S. 60/592,208, U.S. 60/591,775 and U.S. 60/612,823 show objective designs which can be optimized by and combined with the use of materials and teachings according to this application. --

On page 2, lines 11-14, please amend the text as follows:

-- PCT application entitled "Microlithography Projection Objective with Crystal Elements", inventor Karl-Heinz Schuster, International Application No. PCT/EP2004/014100, filed on Dec. 10, 2004, published as WO/2005/059645 on June 30, 2005, internal reference 04213 P PCT, assigned to the same assignee teaches the case of certain non-cubic crystals in this context. Each can be combined with this invention. --